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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/848,997	05/04/2001	Lup San Leong	1016-013	8978
22898 75	590 07/03/2002			
THE LAW OFFICES OF MIKIO ISHIMARU 1110 SUNNYVALE-SARATOGA ROAD SUITE A1			EXAMINER	
			GUERRERO, MARIA F	
SUNNYVALE	SUNNYVALE, CA 94087 .		17777	
			ART UNIT	PAPER NUMBER
			2822	
			DATE MAILED: 07/03/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)
Office Action Summary		09/848,997	LEONG, LUP SAN
		Examiner	Art Unit
		Maria Guerrero	2822
The MAILING DATE of Period for Reply	this communication appear	ars on the cover shet with	the correspondenc address
A SHORTENED STATUTOR THE MAILING DATE OF THI - Extensions of time may be available us after SIX (6) MONTHS from the mailin - If the period for reply specified above i - If NO period for reply is specified above - Failure to reply within the set or extend - Any reply received by the Office later it earned patent term adjustment. See 3	nder the provisions of 37 CFR 1.136(g date of this communication. s less than thirty (30) days, a reply wi e, the maximum statutory period will ded period for reply will, by statute, ca han three months after the mailing da	a). In no event, however, may a repl ithin the statutory minimum of thirty (3 apply and will expire SIX (6) MONTH	ly be timely filed 30) days will be considered timely. S from the mailing date of this communication.
Status	511 1.754(b).		
1) Responsive to commu	inication(s) filed on <u>11 Jun</u>	<u>ne 2002</u> .	
2a) This action is FINAL .	2b)⊠ This	action is non-final.	
3) Since this application in closed in accordance to Disposition of Claims	is in condition for allowand with the practice under <i>Ex</i>	e except for formal matter parte Quayle, 1935 C.D.	rs, prosecution as to the merits is 11, 453 O.G. 213.
4)⊠ Claim(s) <u>1-20</u> is/are pe	nding in the application.		
4a) Of the above claim(s	s) <u>15-20</u> is/are withdrawn f	from consideration.	
5) Claim(s) is/are a	llowed.		
6)⊠ Claim(s) <u>1-14</u> is/are reje	ected.		
7) Claim(s) is/are o	bjected to.		
8) Claim(s) are subj	ect to restriction and/or el	ection requirement.	- -
9)☐ The specification is object	cted to by the Examiner.		
10)☐ The drawing(s) filed on _		or b) objected to by the	Examiner
	st that any objection to the dra		
11) The proposed drawing co	orrection filed on is:	a) ☐ approved b) ☐ disag	pproved by the Examiner
If approved, corrected dra	awings are required in reply to	o this Office action.	, , , , , , , , , , , , , , , , , , , ,
12)☐ The oath or declaration is	objected to by the Exami	ner.	
Priority under 35 U.S.C. §§ 119 a	ind 120		
13) Acknowledgment is mad	e of a claim for foreign pri	ority under 35 U.S.C. § 11	9(a)-(d) or (f).
a) ☐ Ali b) ☐ Some * c) ☐			() () ()
1. Certified copies of	the priority documents ha	ve been received.	
	the priority documents ha		cation No.
Copies of the certi	fied copies of the priority d	locuments have been rece	eived in this National Stage
14) Acknowledgment is made	of a claim for domestic pri	ority under 35 U.S.C. & 11	19(e) (to a provisional application).
a) The translation of the 15) Acknowledgment is made	e foreign language provision	onal application has been	received
) Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Draw) Information Disclosure Statement(s) (ing Review (PTO-948)	4) Interview Summ 5) Notice of Inform 6) Other:	nary (PTO-413) Paper No(s) nal Patent Application (PTO-152)
S. Patent and Trademark Office FO-326 (Rev. 04-01)	Office Action S	Summanı	Part of Paper No. 4

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DETAILED ACTION

This Office Action is in response to the Election filed June 11, 2002.
 Claims 1-20 are pending.

Election/Restrictions

2. Applicant's election of Group I claims 1-14 in Paper No. 3 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).

Claims 15-20 are withdrawn from further consideration pursuant to 37 CFR 1.142(b), as being drawn to a nonelected invention, there being no allowable generic or linking claim. Applicant timely traversed the restriction (election) requirement in Paper No. 3.

Claim Objections

3. Claim 7 is objected to because of the following informalities: the term "bake" is misspelled in claim 7, line 10. Appropriate correction is required.

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Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in-
- (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or
- (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).
- 4. Claims 1-2 are rejected under 35 U.S.C. 102(b) as being anticipated by Long et al. (U.S. 5,173,766).

Long et al. teaches placing a semiconductor wafer having an interlevel dielectric layer (ILD) on a wafer holder of an oven, applying mechanical pressure to the ILD layer using a mechanical device, and applying heat simultaneously with the mechanical pressure (Fig. 11, col. 14, lines 23-35, col. 32, lines 60-68, col. 33, lines 3-6). Long et al. shows applying the mechanical pressure includes relative motion to assist in planarization (col. 24, lines 7-20).

5. Claims 1-6 are rejected under 35 U.S.C. 102(e) as being anticipated by Levert et al. (U.S. 6,407,006).

Levert et al. teaches placing a semiconductor wafer having an interlevel dielectric layer (ILD) on a wafer holder of an oven, applying mechanical pressure to the ILD layer

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using a mechanical device, applying heat simultaneously with the mechanical pressure (col. 7, lines 60-68, col. 26, lines 24-26). Levert et al. shows applying the mechanical pressure includes relative motion to assist in planarization, providing a non-sticking motion, sensing and controlling the temperature of the mechanical device (Abstract, col. 8, lines 5-15). Levert et al. shows the mechanical device using a roller (col. 7, lines 20-27).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claims 7-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Levert et al. (U.S. 6,407,006) in view of Oaks et al. (U.S. 6,083,661).

Levert et al. teaches placing a semiconductor wafer having an interlevel dielectric layer (ILD) on a wafer holder of an oven, applying mechanical pressure to the ILD layer using a mechanical device, applying heat simultaneously with the mechanical pressure (col. 7, lines 60-68, col. 26, lines 24-26). Levert et al. shows applying the mechanical pressure includes relative motion to assist in planarization, providing a non-sticking motion, sensing and controlling the temperature of the mechanical device (Abstract, col. 8, lines 5-15). In addition, Levert et al. teaches spinning a low dielectric constant ILD material and curing the low dielectric constant ILD material (col. 3, lines 10-15, 53-60,

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col. 7, lines 45-65, col. 17, lines 17-55). Levert et al. shows the mechanical device using a roller (col. 7, lines 20-27). Furthermore, Levert et al. teaches an annealing process (col. 24, lines 53-60).

Levert et al. does not specifically describe soft baking the low dielectric constant ILD material at a soft bake temperature, holding the low dielectric constant ILD material at a temperature below the hard bake temperature (between 100°C and 400°C). However, Oaks et al. describes soft baking the low dielectric constant ILD material at a soft bake temperature, holding the low dielectric constant ILD material at a temperature below the hard bake temperature (between 100°C and 400°C), and hard baking the low dielectric constant ILD material (col. 16, lines 60-65, col. 17, lines 10-15, col. 19, lines 65-67).

Therefore, it would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Levert et al.'s process by specify the use of a conventional soft bake as taught Oaks et al. in order to remove the solvent not removed during the spin-coating process (Oaks et al., col. 19, lines 65-67).

Conclusion

7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Robinson (U.S. 6,103,638), Paranjpe (U.S. 5,434,107), Matsuda et al. (U.S. 5,679,610), Doan et al. (U.S. 6,331,488), Potter (U.S. 4,794,021), Blalock (U.S. 5,967,030) teach a planarization process.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Maria Guerrero whose telephone number is 703-305-0162.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 703-308-4940. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

I ← G MG June 27, 2002

CARL WHITEHEAD, JR.
SUPERVISORY PATENT EXAMINEF
TECHNOLOGY CENTER 2800